

Supplementary Figure 2. Using the TEC of monolayer MoS₂ reported in previous literature, numerical simulation results of the strain distribution in bare MoS₂ at 200 K, 300K, 400 K and 500K, respectively.

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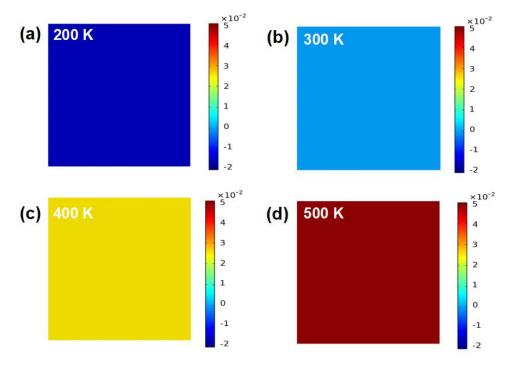
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Supplementary Figure 4. Adopting the TEC of monolayer MoS_2 obtained in this work, numerical simulation results of the strain distribution in bare MoS_2 at 200 K, 300K, 400 K and 500K, respectively.